# IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Patrick J. Evans

Attorney Docket No.: AGIT117605

Title:

DISSOLVED HYDROGEN ANALYZER

## PRELIMINARY AMENDMENT

Seattle, Washington 98101

#### TO THE COMMISSIONER FOR PATENTS:

Please amend the above-referenced divisional patent application as follows

# In the Specification:

At page 1, after the title, please enter the following information:

#### CROSS-REFERENCE TO RELATED APPLICATION

The present application is a divisional of prior United States Patent Application No. 09/273,958, filed on March 22, 1999, priority from the filing date of which is hereby claimed under 35 U.S.C. § 120. The entire disclosure of the prior application, from which priority is claimed, is considered as being part of the disclosure of this application and is hereby incorporated by reference herein.

#### **GOVERNMENT RIGHTS**

#### In the Claims:

Please cancel Claims 1-19 and amend Claim 22 as follows:

- 20. A process for measuring the amount of dissolved hydrogen in a solution comprising the steps of:
  - (a) equilibration of liquid containing dissolved hydrogen with a carrier gas;
  - (b) removal of oxygen from the carrier gas containing hydrogen; and
- (c) measuring the amount of hydrogen in the carrier gas that has been treated to remove oxygen.
  - 21. The process of Claim 20, wherein said removal step neither consumes nor

LAW OFFICES OF CHRISTENSEN O'CONNOR JOHNSON KINDNESS\*\*LLC 1420 Fifth Avenue Suite 2800 Seattle, Washington 98101 206.682.8100 produces hydrogen.

- 22. (Amended) The process of Claim 20, wherein step (b) further comprises removal of carbon monoxide from the carrier gas containing hydrogen.
- 23. The process of Claim 20, wherein step (b) further comprises removal of sulfur compounds from the carrier gas containing hydrogen.
- 24. The process of Claim 20, wherein step (b) further comprises removal of moisture from the carrier gas containing hydrogen.
- 25. The process of Claim 20, wherein a metal oxide semiconductor is used to measure the concentration of hydrogen.
- 26. The process of Claim 25 wherein hydrogen concentration is measured by monitoring an output voltage from the metal oxide semiconductor and calculating the rate of voltage increase.
- 27. The process of Claim 20, wherein step (b) further comprises the removal of carbon monoxide at a temperature of 55°C to 80°C.
- 28. The process of Claim 20, wherein in step (a) the liquid containing dissolved hydrogen is an aqueous sample of contaminated groundwater, further comprising a step (d) of determining the status of bioremediation using the hydrogen content measured in step (c).
- 29. The process of Claim 28, wherein step (d) comprises monitoring hydrogen content to determine the status of natural attenuation of contaminants.

### **REMARKS**

The Examiner is requested to enter the foregoing amendments to the specification and claims.

Respectfully submitted,

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# VERSION WITH MARKINGS TO SHOW CHANGES MADE JUNE 20, 2001 In the Specification:

A new section has been added on page 1 after the title, as follows.

## **CROSS-REFERENCE TO RELATED APPLICATION**

The present application is a divisional of prior United States Patent Application No. 09/273,958, filed on March 22, 1999, priority from the filing date of which is hereby claimed under 35 U.S.C. § 120. The entire disclosure of the prior application, from which priority is claimed, is considered as being part of the disclosure of this application and is hereby incorporated by reference herein.

#### **GOVERNMENT RIGHTS**

- 20. A process for measuring the amount of dissolved hydrogen in a solution comprising the steps of:
  - (a) equilibration of liquid containing dissolved hydrogen with a carrier gas;
  - (b) removal of oxygen from the carrier gas containing hydrogen; and
- (c) measuring the amount of hydrogen in the carrier gas that has been treated to remove oxygen.
- 21. The process of Claim 20, wherein said removal step neither consumes nor produces hydrogen.
- 22. (Amended) The process of Claim 20, wherein step [(6)] (b) further comprises removal of carbon monoxide from the carrier gas [continuing] containing hydrogen.
- 23. The process of Claim 20, wherein step (b) further comprises removal of sulfur compounds from the carrier gas containing hydrogen.
- 24. The process of Claim 20, wherein step (b) further comprises removal of moisture from the carrier gas containing hydrogen.
- 25. The process of Claim 20, wherein a metal oxide semiconductor is used to measure the concentration of hydrogen.
  - 26. The process of Claim 25 wherein hydrogen concentration is measured by

monitoring an output voltage from the metal oxide semiconductor and calculating the rate of voltage increase.

- 27. The process of Claim 20, wherein step (b) further comprises the removal of carbon monoxide at a temperature of 55°C to 80°C.
- 28. The process of Claim 20, wherein in step (a) the liquid containing dissolved hydrogen is an aqueous sample of contaminated groundwater, further comprising a step (d) of determining the status of bioremediation using the hydrogen content measured in step (c).
- 29. The process of Claim 28, wherein step (d) comprises monitoring hydrogen content to determine the status of natural attenuation of contaminants.